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**CONFIRMATION NO. 1510** 

**FILING DATE ATTORNEY** 01/19/2005 **SERIAL NUMBER CLASS GROUP ART UNIT** DOCKET NO. 10/522,036 430 1752 SHIGA7.004APC RULE **APPLICANTS** Kenji Maruyama, Kawasaki-shi, JAPAN; Masaki Kurihara, Kawasaki-shi, JAPAN; Ken Miyagi, Kawasaki-shi, JAPAN; Satoshi Niikura, Kawasaki-shi, JAPAN; Satoshi Shimatani, Kawasaki-shi, JAPAN; Masahiro Masujima, Kawasaki-shi, JAPAN; Kazuyuki Nitta, Kawasaki-shi, JAPAN; Toshihiro Yamaguchi, Kawasaki-shi, JAPAN; Kousuke Doi, Kawasaki-shi, JAPAN; This application is a 371 of PCT/JP04/07139 05/19/2004 SJL JAPAN 2003141805 05/20/2003 JAPAN 2003426503 12/24/2003 Foreign Priority claimed yes 🗖 ne STATE OR SHEETS TOTAL INDEPENDENT 四 35 USC 119 (a-d) conditions yes Omo Met after met Allawance SJL Vorified and COUNTRY DRAWING **CLAIMS CLAIMS** Examiner's Signature Acknowledged Initials **JAPAN** 0 38 Δ ADDRESS 20995 KNOBBE MARTENS OLSON & BEAR LLP 2040 MAIN STREET FOURTEENTH FLOOR IRVINE , CA 92614 TITLE Chemically amplified positive photo resist composition and method for forming resist pattern